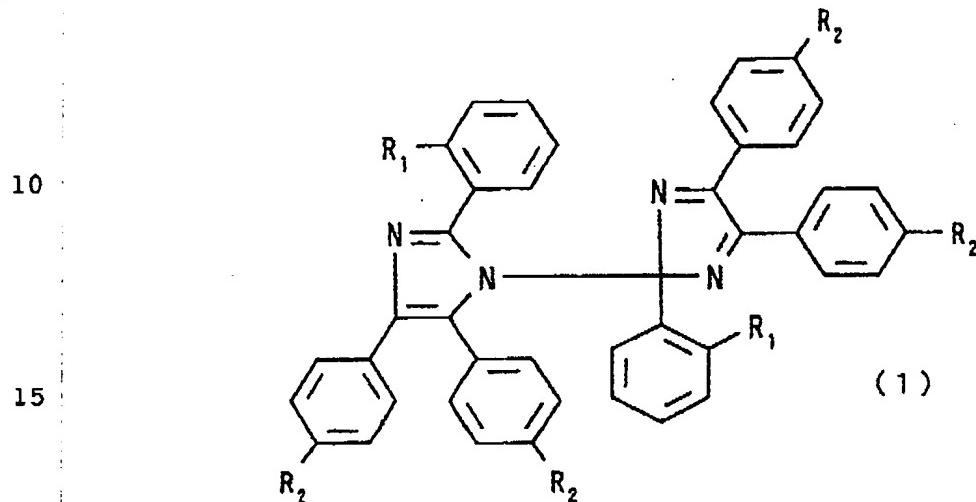


ABSTRACT

The present invention provides a novel
hexaarylbiimidazole compound of the following formula
5 (1):



wherein each R₁ represents a halogen, and each R₂
20 represents an optionally substituted C₁₋₄ alkyl group.

The hexaarylbiimidazole compound of the present
invention is useful as photoradical generators in
photopolymerizable compositions used as resists and is
characterized by low sublimating thermal decomposition
25 products. The photopolymerizable compositions may be
suitably used as resists or as color filters for color
liquid crystal display elements, cameras and the like.